

## UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address COMMISSIONER FOR PATENTS P.O. Dex 1450 Alexandria, Virginia 22313-1450

APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/015,500		2/11/2001	Amit Datta	7129.045	7129.045 6537	
25546	7590	08/20/2003				
DREIER &		LLP	EXAMINER			
499 PARK AVENUE 20TH FLOOR				WONG, EDNA		
NEW YOR	K, NY 100	022		ART UNIT	PAPER NUMBER	
				1753		
				DATE MAILED: 08/20/2003	DATE MAILED: 08/20/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

· · · · · ·			h
<del></del>	Application No.	Applicant(s)	
	10/015,500	DATTA, AMIT	
Office Action Summary	Examiner	Art Unit	
	Edna Wong	1753	
Th MAILING DATE of this communication Period for Reply	n appears on the cov r sheet w	ith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICATI  - Extensions of time may be available under the provisions of 37 C after SIX (6) MONTHS from the mailing date of this communicati  - If the period for reply specified above is less than thirty (30) days  - If NO period for reply is specified above, the maximum statutory  - Failure to reply within the set or extended period for reply will, by  - Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).  Status	ON.  FR 1.136(a). In no event, however, may a on.  , a reply within the statutory minimum of thi period will apply and will expire SIX (6) MOI statute, cause the application to become A	reply be timely filed ty (30) days will be considered timely. NTHS from the mailing date of this communicat BANDONED (35 U.S.C. § 133).	ion.
1) Responsive to communication(s) filed or	1 <u> </u>		
2a)☐ This action is <b>FINAL</b> . 2b)⊠	This action is non-final.		
3) Since this application is in condition for a closed in accordance with the practice u			s is
Disposition of Claims			
4)⊠ Claim(s) <u>1-21</u> is/are pending in the applic			
4a) Of the above claim(s) is/are wit	hdrawn from consideration.	•	
5) Claim(s) is/are allowed.			
6) Claim(s) is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) <u>1-21</u> are subject to restriction an	d/or election requirement.		
Application Papers		•	
9) The specification is objected to by the Exa			
10)☐ The drawing(s) filed on is/are: a)☐			
Applicant may not request that any objection	• • • • • • • • • • • • • • • • • • • •	,	
11) The proposed drawing correction filed on		disapproved by the Examiner.	
12) The oath or declaration is objected to by the			
Priority under 35 U.S.C. §§ 119 and 120	ie Examiner.		
13) Acknowledgment is made of a claim for fo	projan priority under 25 LLS C	\$ 110(a) (d) or (f)	
· -	reigh phonty under 35 0.5.C.	3 119(a)-(u) 01 (1).	
a) ☐ All b) ☐ Some * c) ☐ None of:			
1. ☐ Certified copies of the priority docu		Analization No.	
2. Certified copies of the priority docu			•
<ul> <li>3. Copies of the certified copies of the application from the Internation</li> <li>* See the attached detailed Office action for</li> </ul>	al Bureau (PCT Rule 17.2(a)).		
14)☐ Acknowledgment is made of a claim for do	mestic priority under 35 U.S.C.	§ 119(e) (to a provisional applica	ation).
a) ☐ The translation of the foreign languag	• • • • • • • • • • • • • • • • • • • •		
Attachment(s)	· •		
1) Notice of References Cited (PTO-892)	4) Interview	Summary (PTO-413) Paper No(s)	

U.S. Patent and Trademark Office PTOL-326 (Rev. 04-01)

2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)

5) Notice of Informal Patent Application (PTO-152)
6) Other:

## Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 1-7 and 21, drawn to a metal contact for a copper alloy, classified in class 428, subclass 409.
- II. Claims 8-20, drawn to a method of forming a metal contact having a barrier layer ranging from about 0.00001 inch to about 0.0001 inch, classified in class 205, subclass 255.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case the product as claimed can be made by another and materially different process such as by physical vapor depositing the barrier layer.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Because these inventions are distinct for the reasons given above and the search required for Group I is not required for Group II, restriction for examination purposes as indicated is proper.

Application/Control Number: 10/015,500

**Art Unit: 1753** 

Page 3

Applicant is advised that the reply to this requirement to be complete must

include an election of the invention to be examined even though the requirement be

traversed (37 CFR 1.143).

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Edna Wong whose telephone number is (703) 308-

3818. The examiner can normally be reached on Mon-Fri 7:30 am to 5:00 pm, alt.

Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Nam Nguyen can be reached on (703) 308-3322. The fax phone number

for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is (703) 308-

1495.

Edna Wong

Primary Examiner

Art Unit 1753

**EW** 

August 15, 2003